



1/19

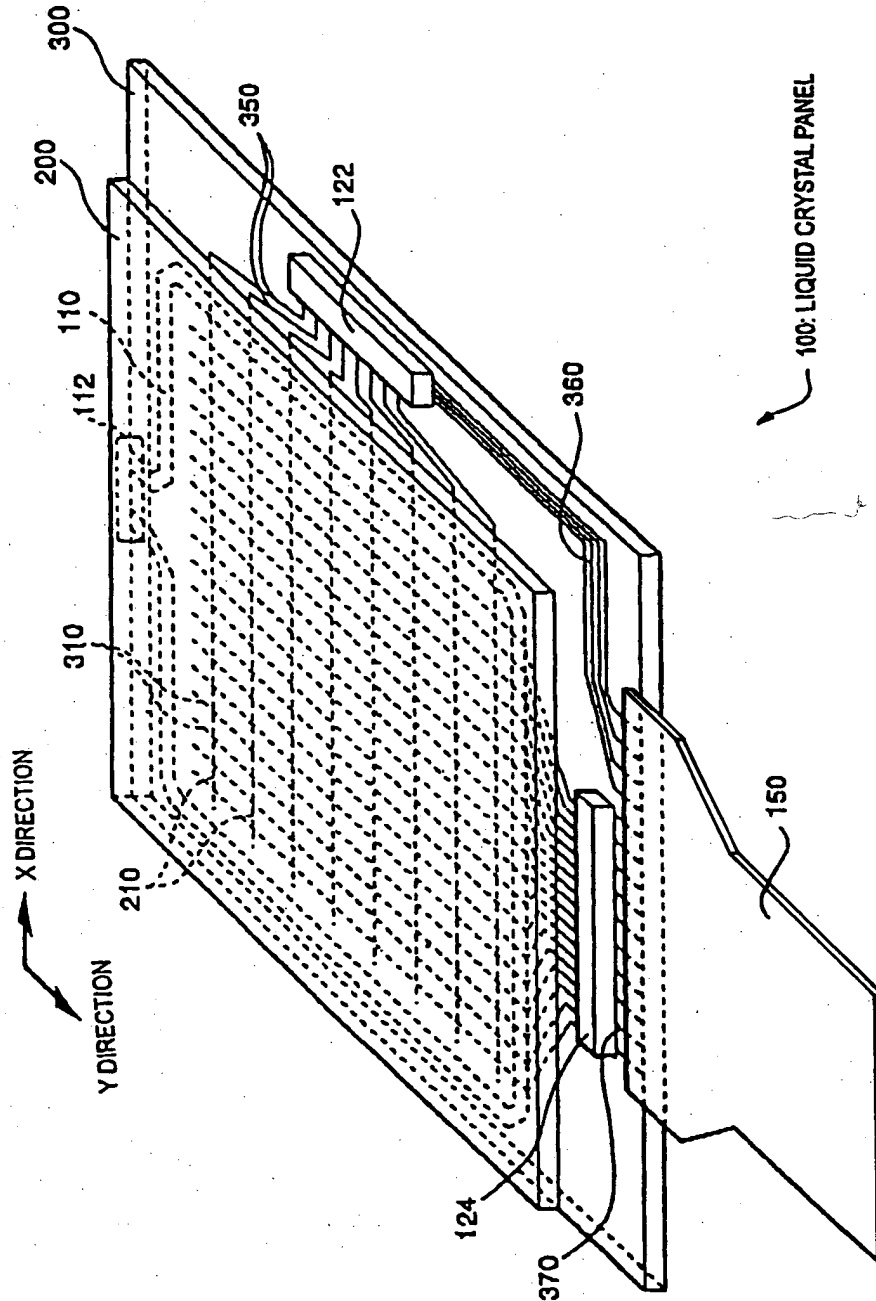
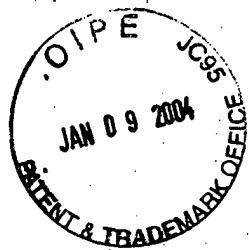


Fig. 1



2/19

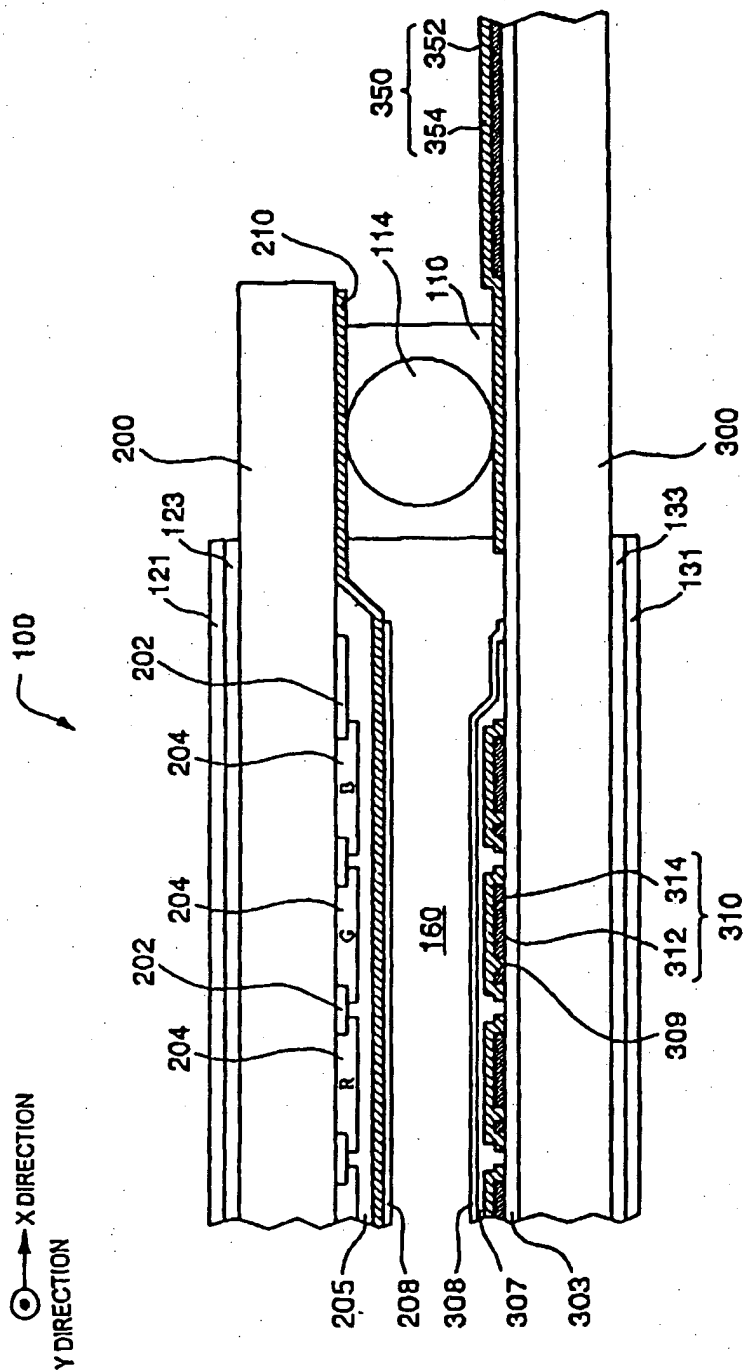
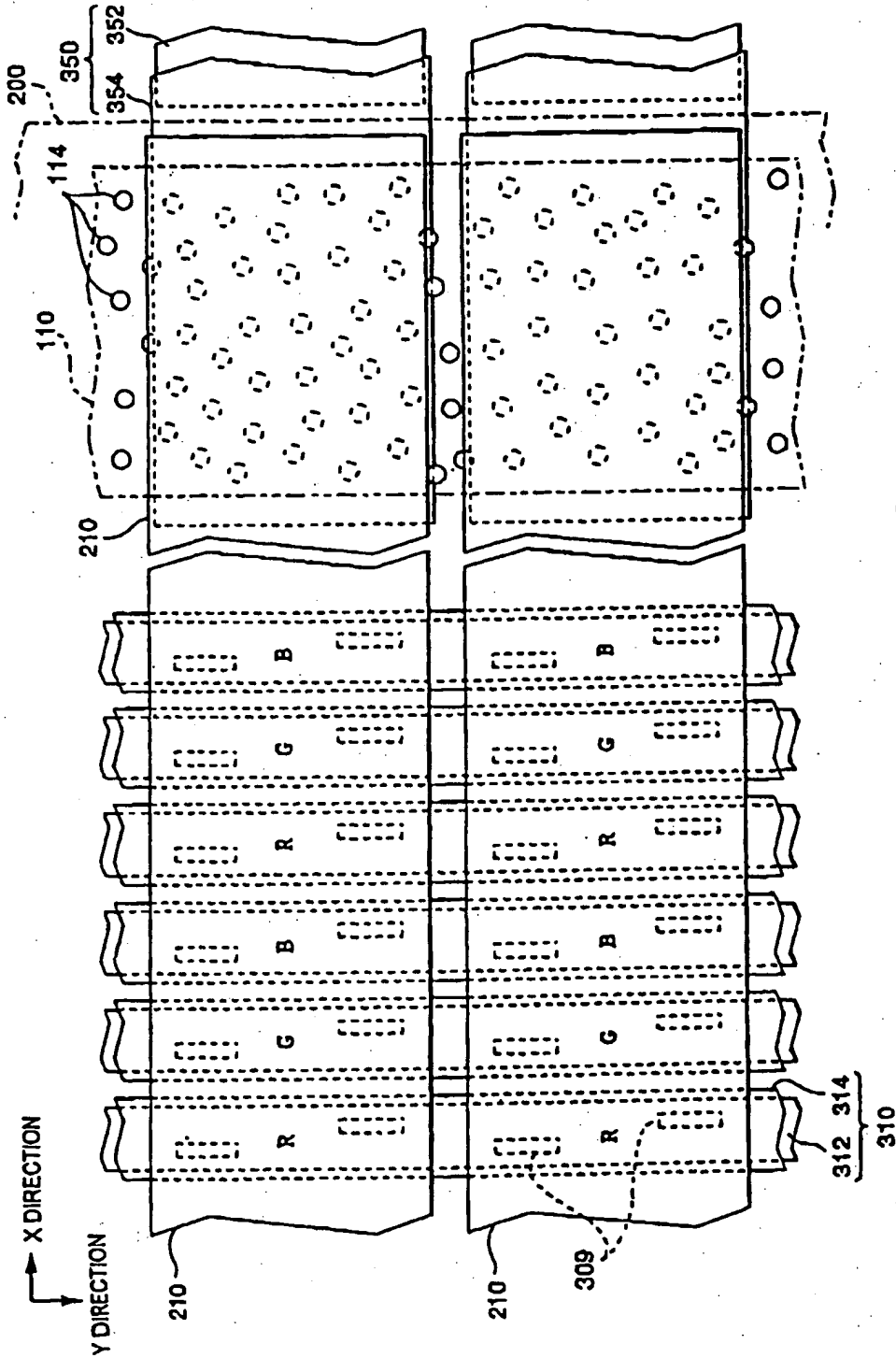


Fig. 2





4/19

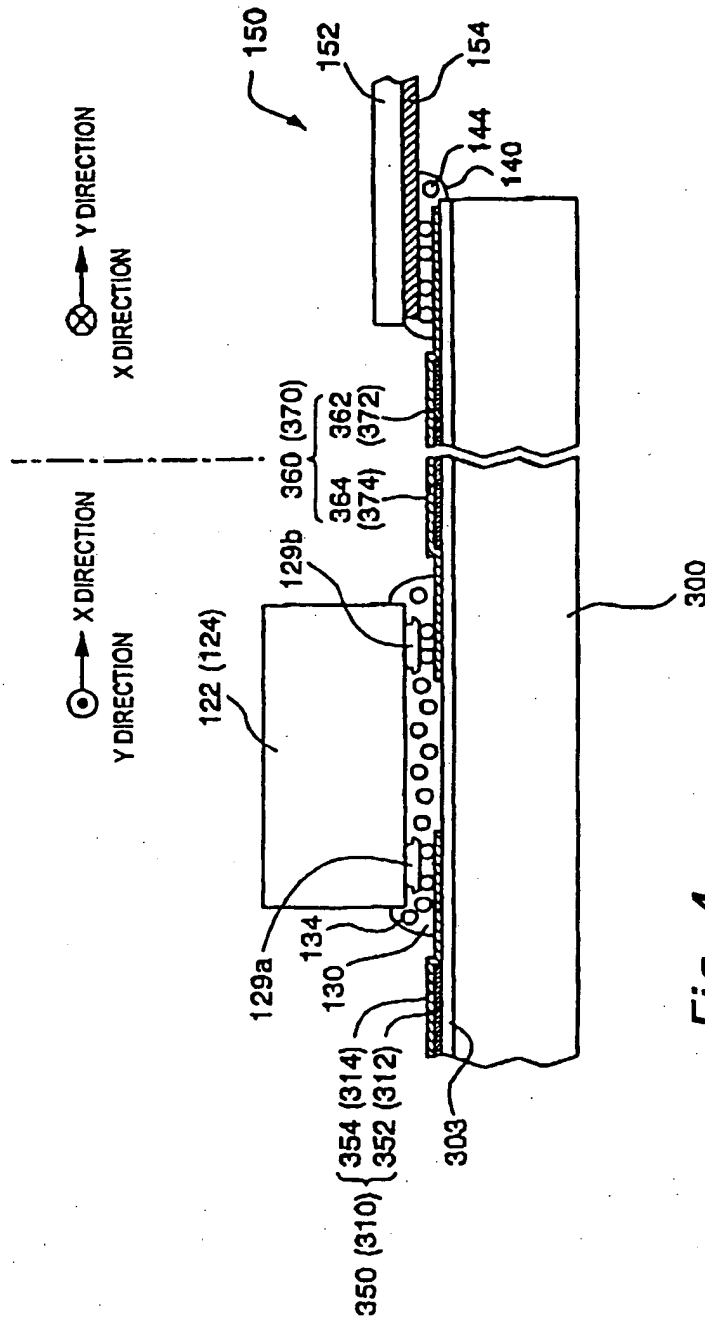
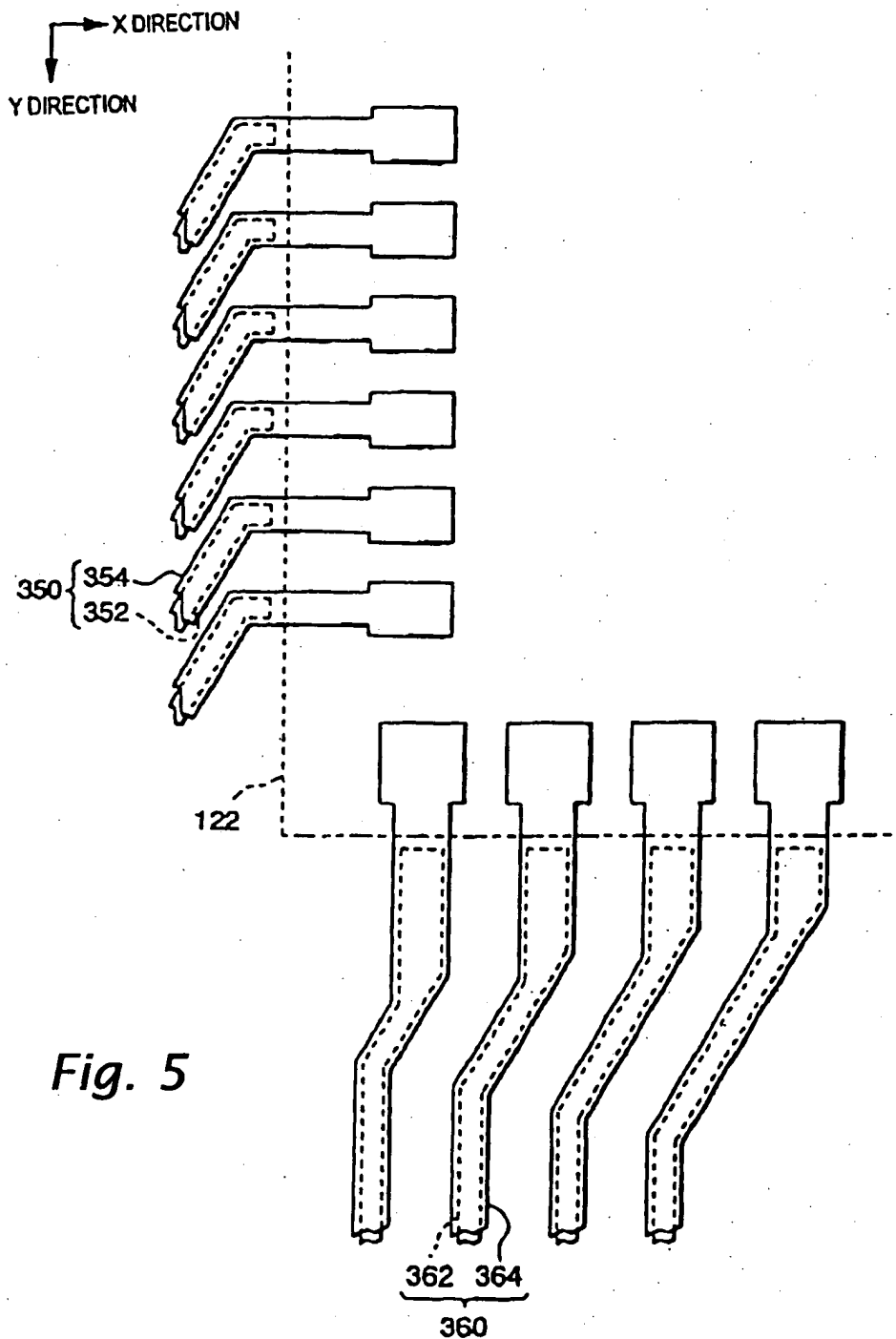


Fig. 4



5/19





6/19

Fig. 6a

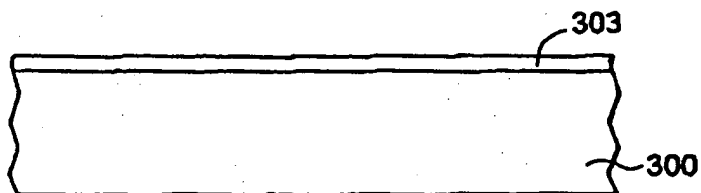


Fig. 6b

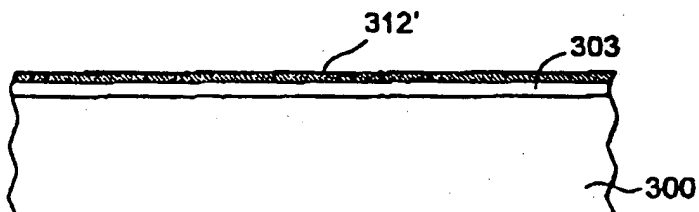


Fig. 6c

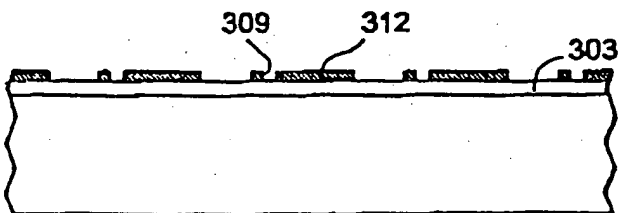


Fig. 6d

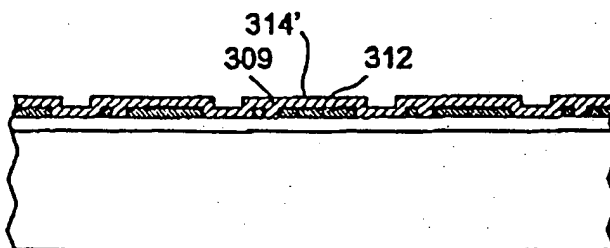
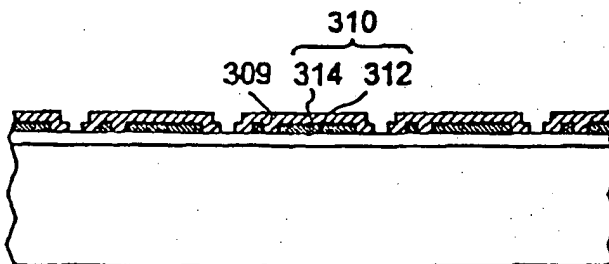


Fig. 6e





7/19

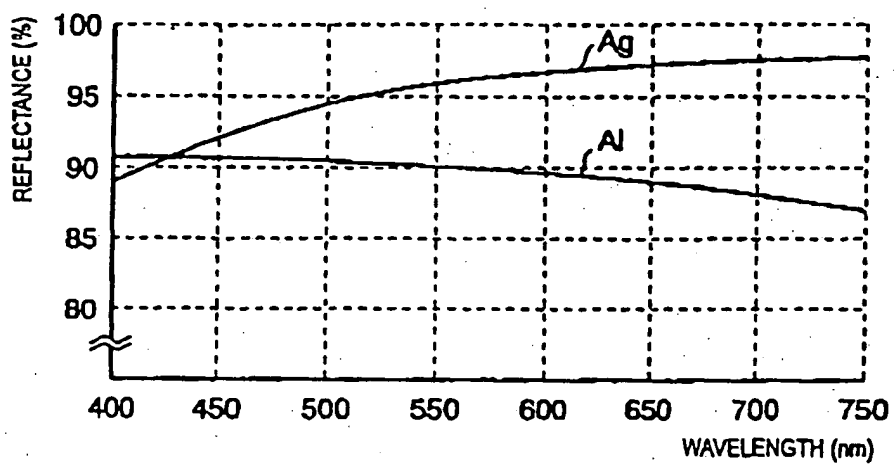


Fig. 7



8/19

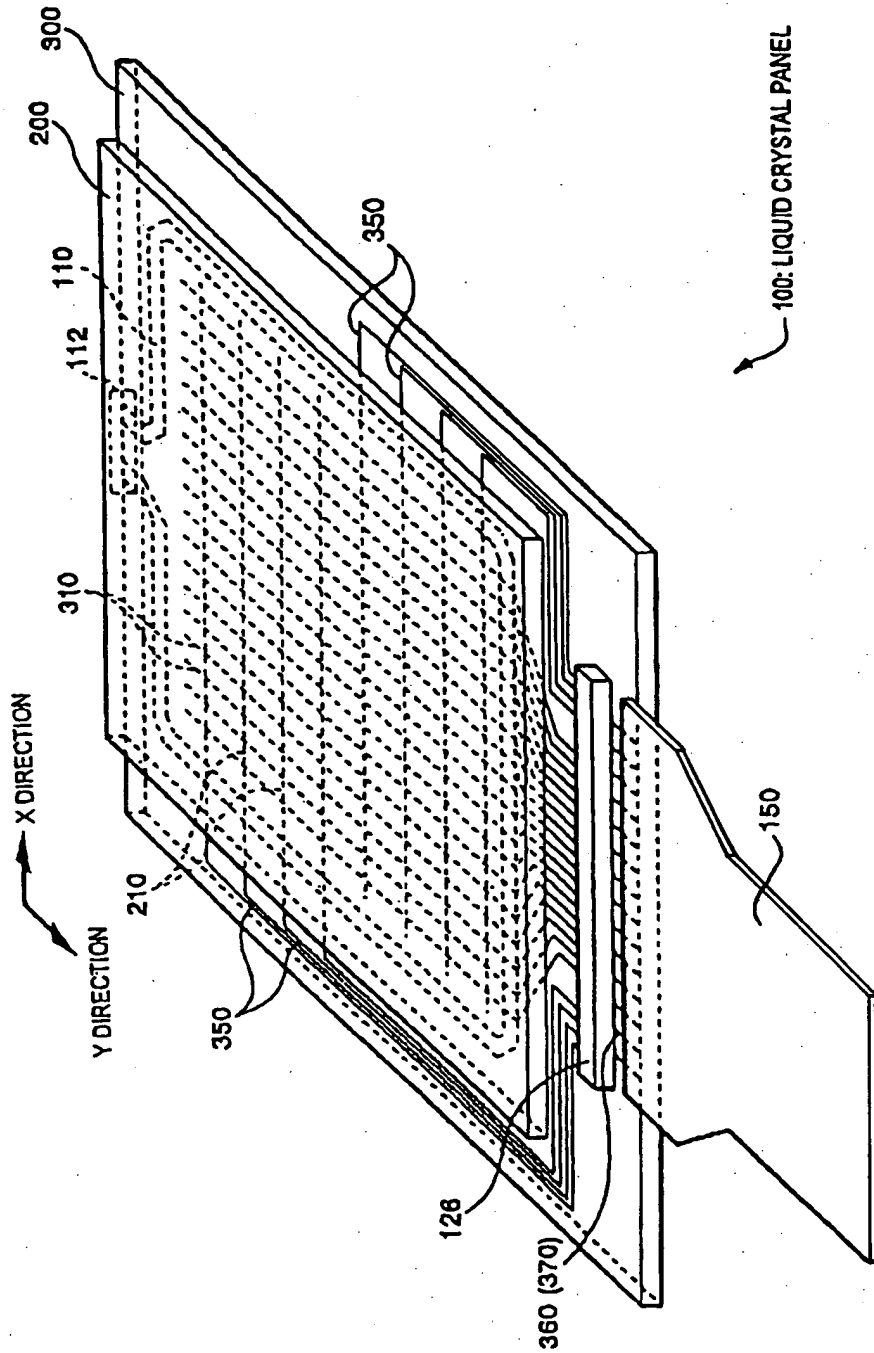


Fig. 8



9/19

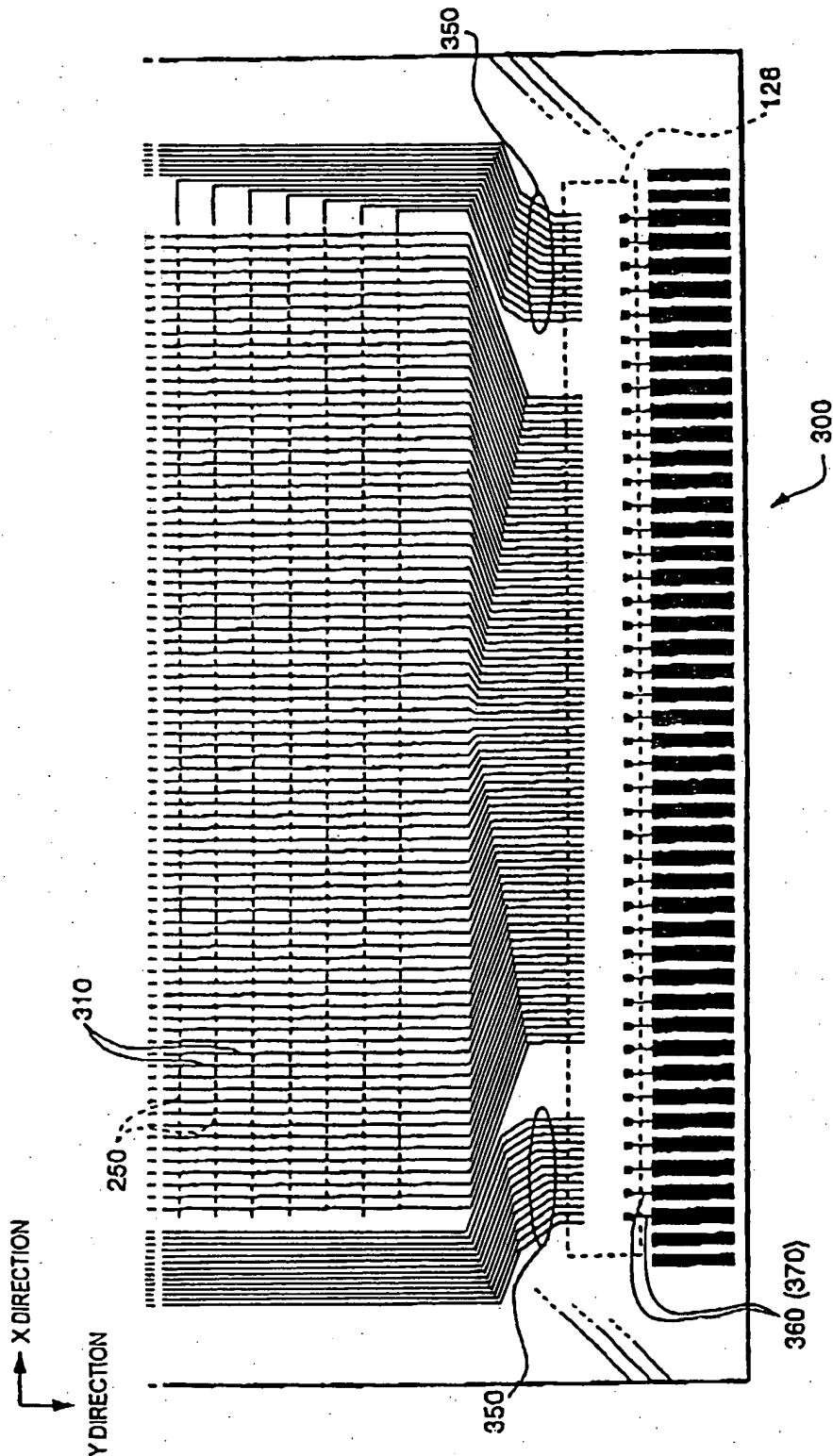


Fig. 9



10/19

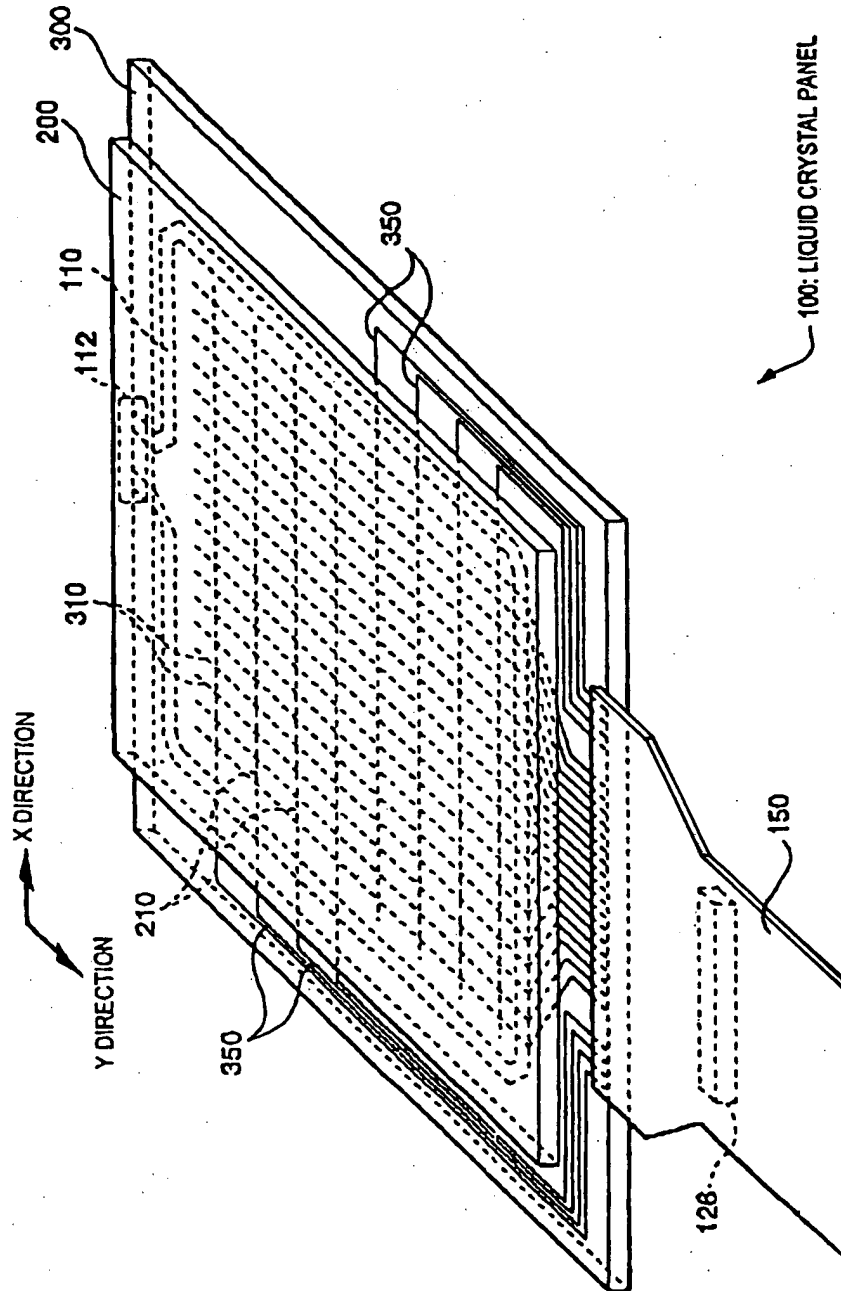


Fig. 10

Fig. 11



12/19

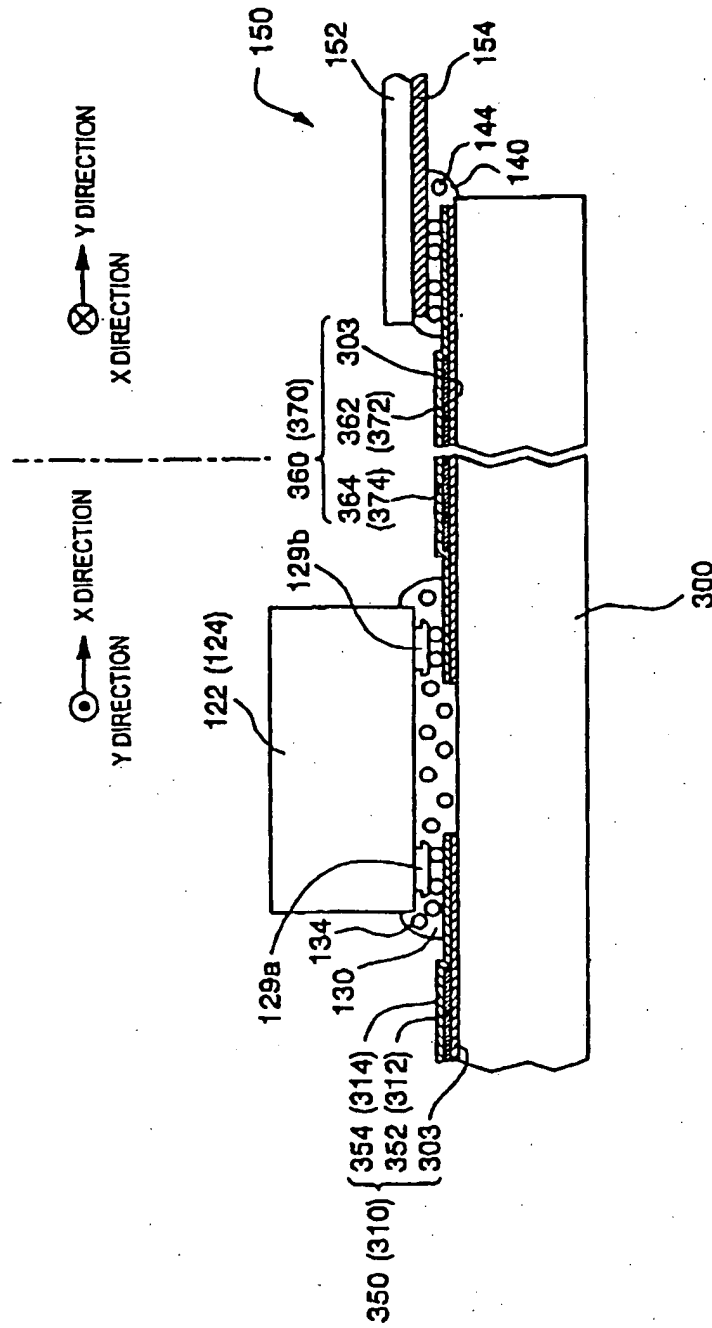


Fig. 12



13/19

Fig. 13a

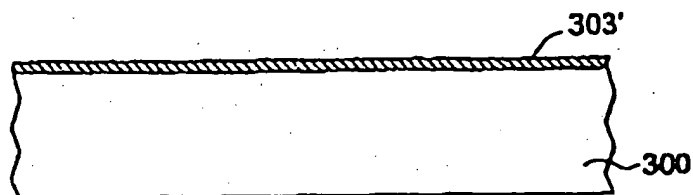


Fig. 13b

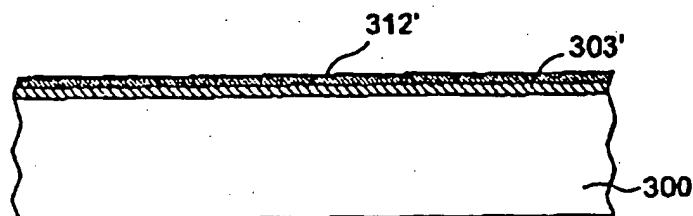


Fig. 13c

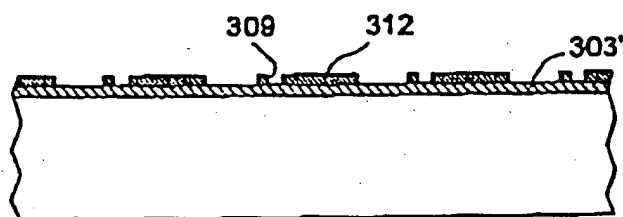


Fig. 13d

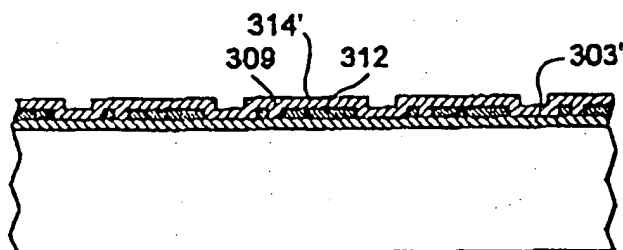
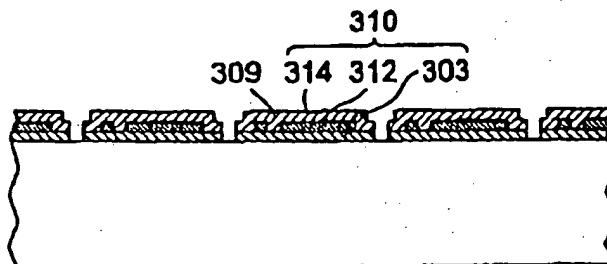
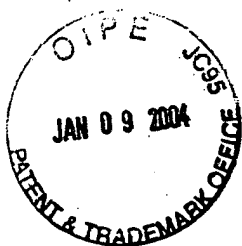


Fig. 13e





14/19

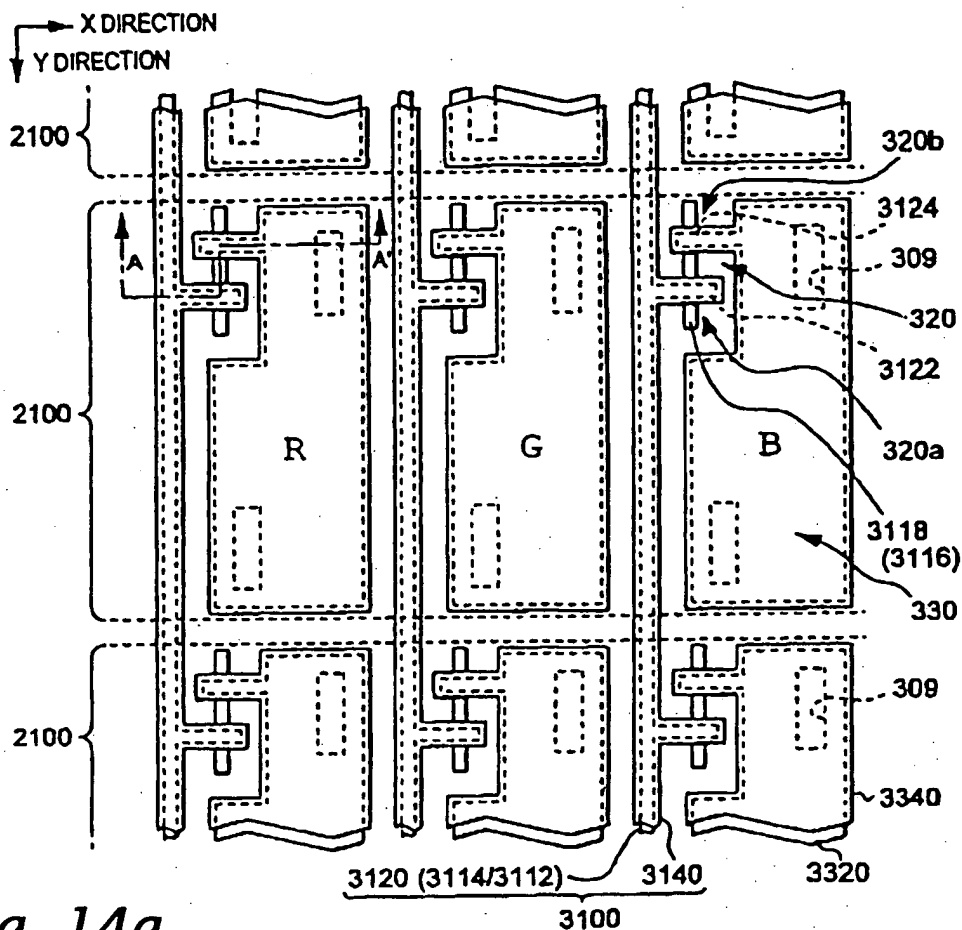


Fig. 14a

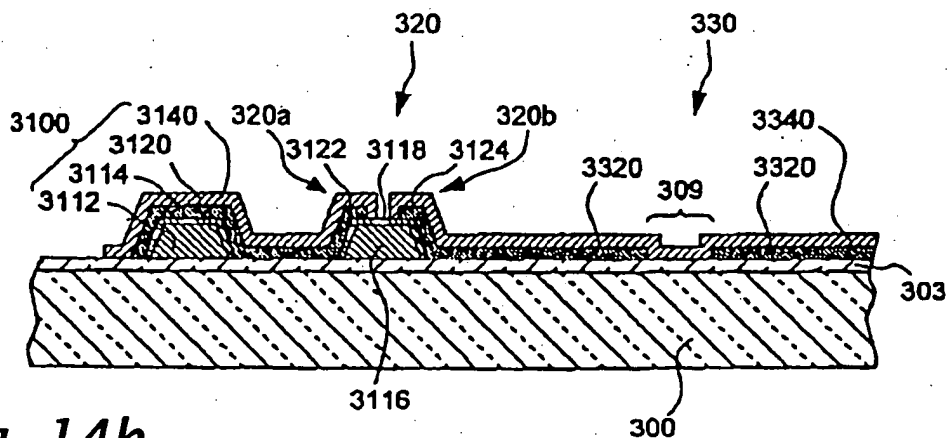


Fig. 14b



15/19

Fig. 15a UNDERLYING FILM DEPOSITION

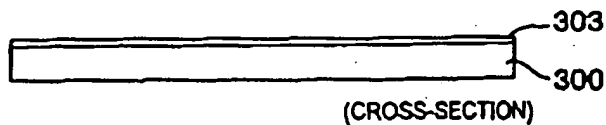


Fig. 15b FIRST METAL FILM DEPOSITION

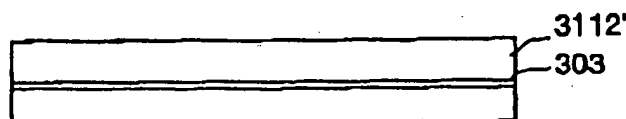


Fig. 15c PATTERNING OF FIRST METAL FILM

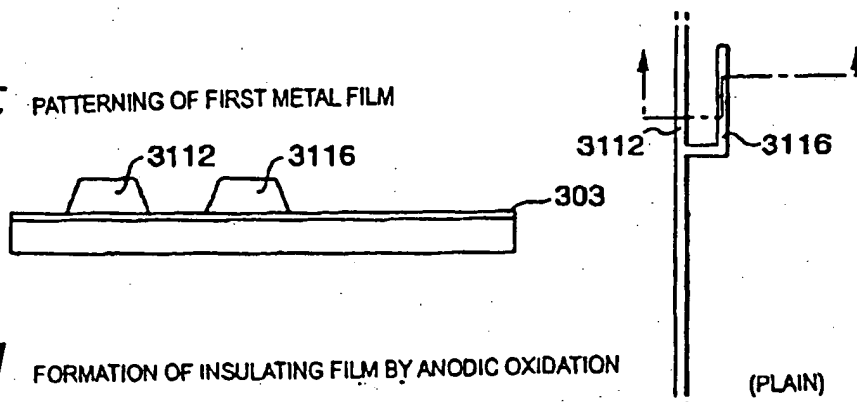


Fig. 15d FORMATION OF INSULATING FILM BY ANODIC OXIDATION

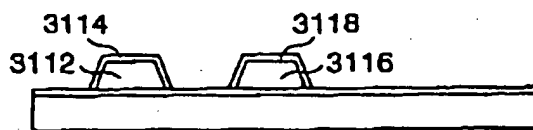
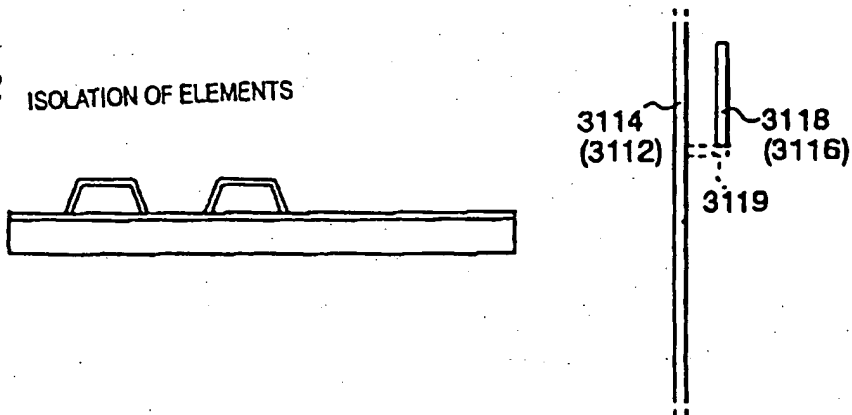


Fig. 15e ISOLATION OF ELEMENTS





16/19

Fig. 16f SECOND METAL FILM (SILVER ALLOY) DEPOSITION

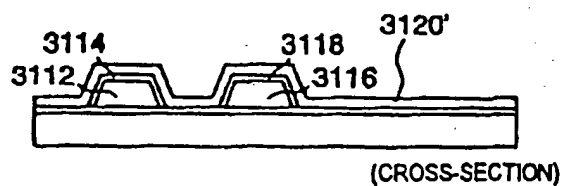
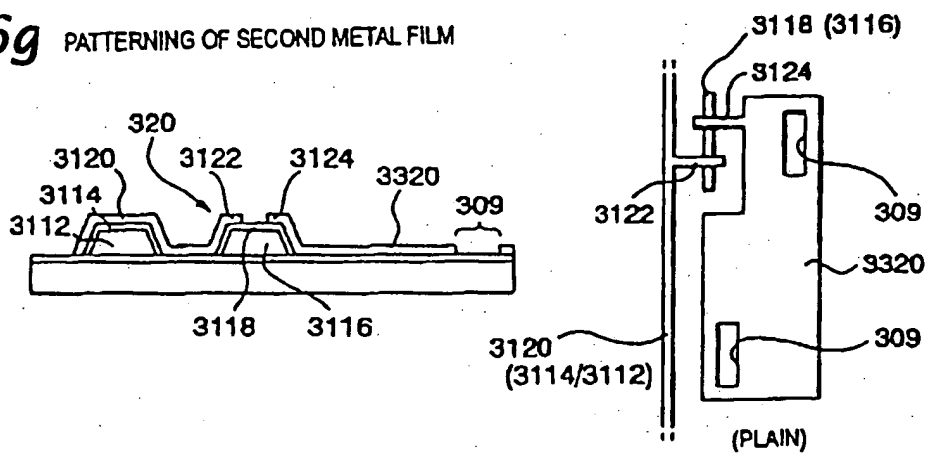


Fig. 16g PATTERNING OF SECOND METAL FILM





17/19

Fig. 17h ITO DEPOSITION

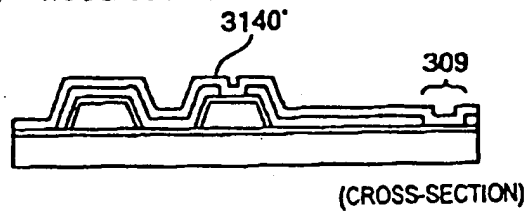
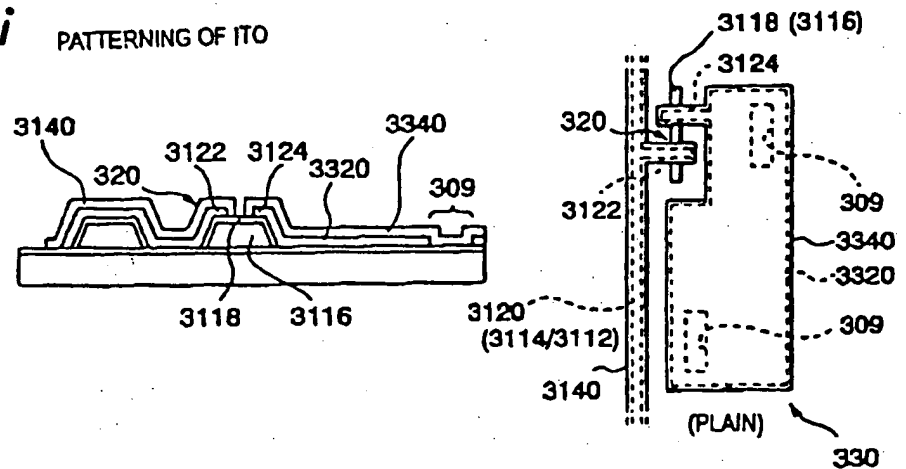


Fig. 17i PATTERNING OF ITO





18/19

Fig. 18

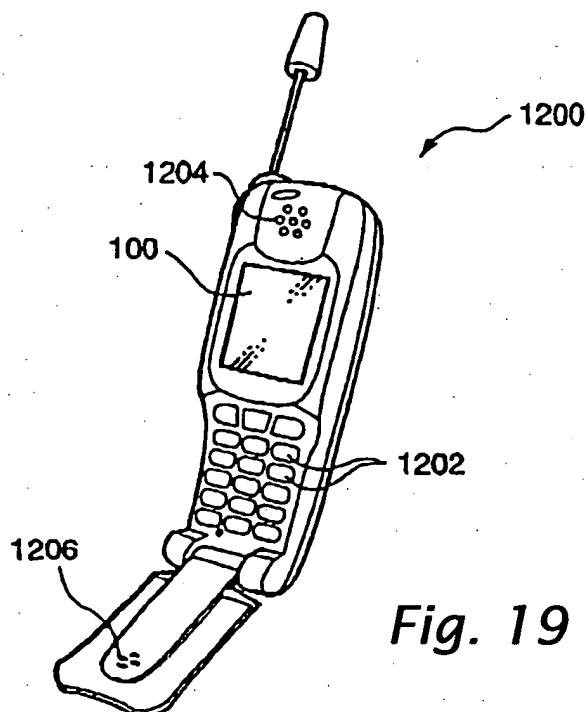
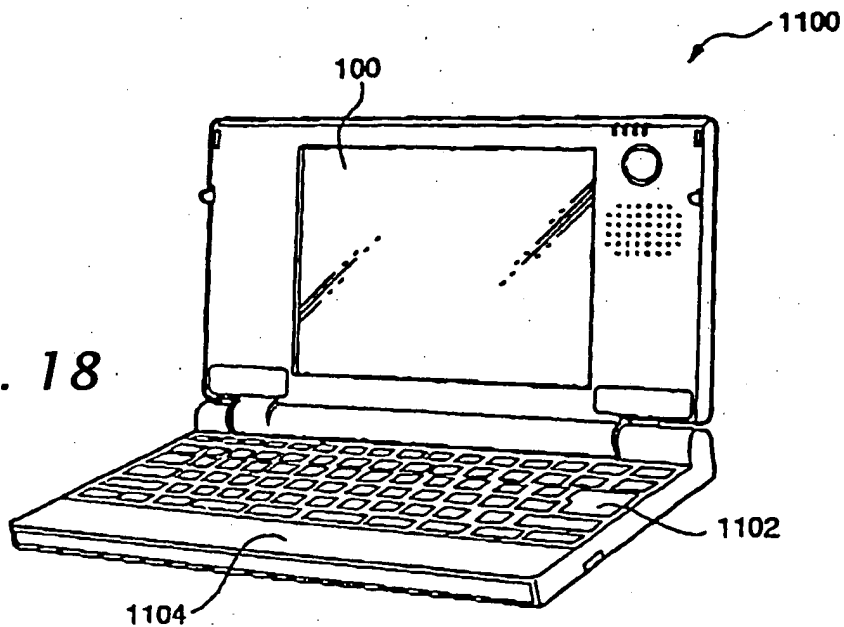


Fig. 19



19/19

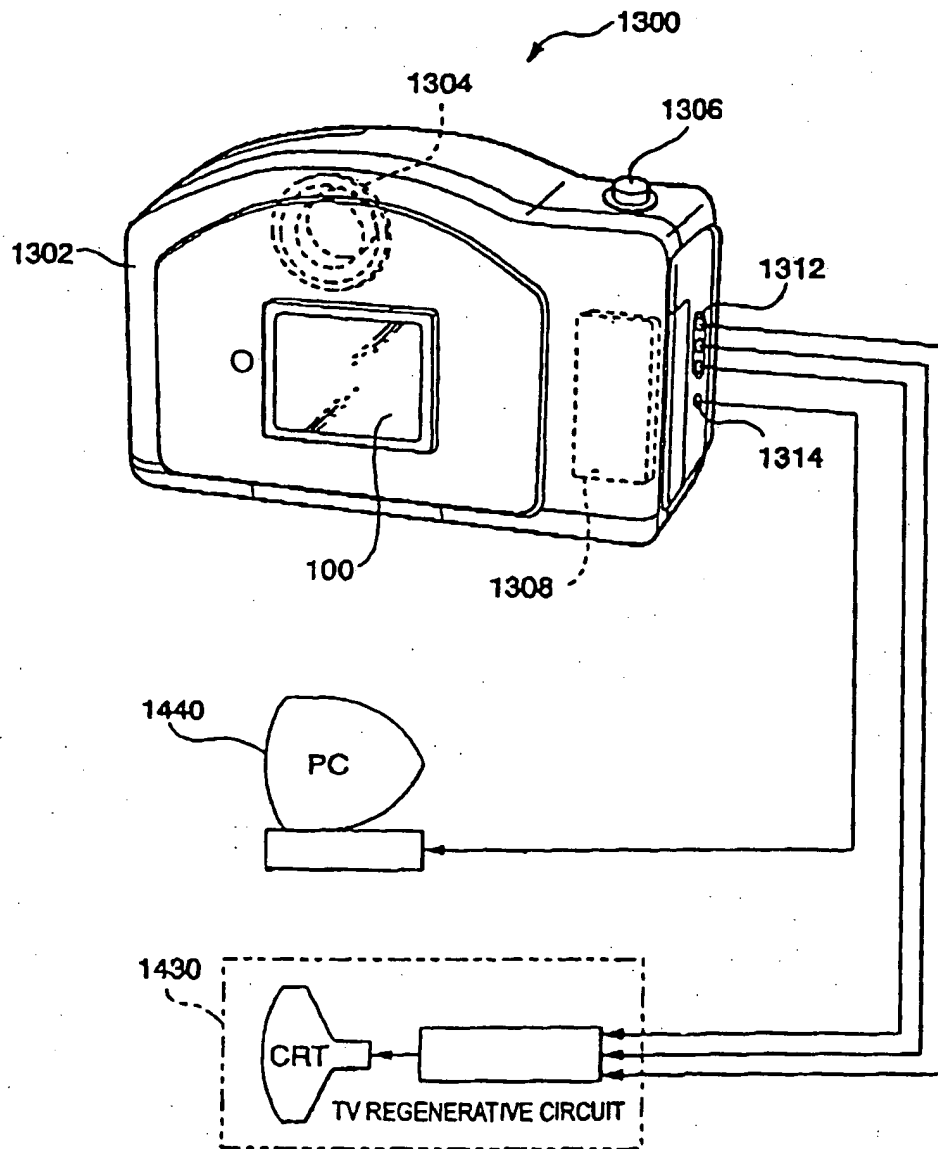


Fig. 20